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(71) Applicant (for all designated States except US): **MOLECULAR IMPRINTS, INC.** [US/US]; 1807 West Braker Ln, Bldg. C-100, Austin, Texas 78758-3605 (US).

(72) Inventors: **CHOI, Byung-Jin**; 11512 Medallion Lane, Austin, Texas 78750 (US). **SREENIVASAN, Sidlgata V.**; 10502 Grand Oak Drive, Austin, Texas 78750 (US).

(74) Agent: **CARTER, Michael D.**; P.O. Box 81536, Austin, Texas 78708-1536 (US).

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(54) Title: METHOD AND SYSTEM FOR DOUBLE-SIDED PATTERNING OF SUBSTRATES

(57) Abstract: The present invention is directed towards a method and a system of patterning first and second opposed sides of a substrate. The method and system may employ a mold assembly and obtaining a desired spatial relationship between the first and second opposed sides of the substrate and the mold assembly. In a further embodiment, the method and system may employ a first and a second mold assembly.



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